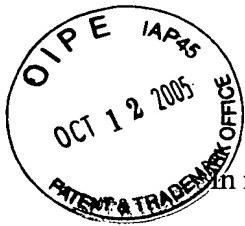


IFW



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Attn: OIPE

Masahiro FURUKAWA et al.

Application No.: 10/531,048

Docket No.: 123487

Filed: April 12, 2005

For: SILICON CARBIDE-BASED CATALYTIC BODY AND PROCESS FOR
PRODUCING THE SAME

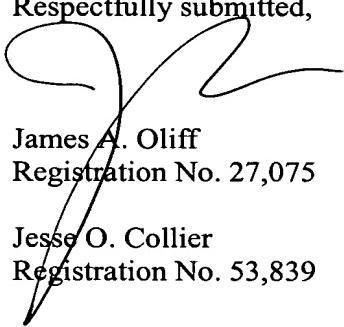
REQUEST FOR CORRECTION OF PALM RECORDS

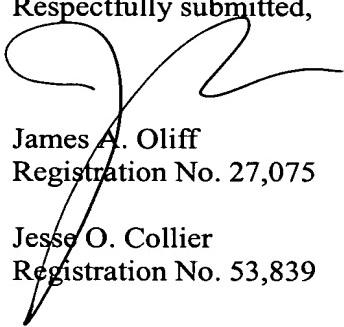
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Respectfully submitted,


James A. Oliff
Registration No. 27,075

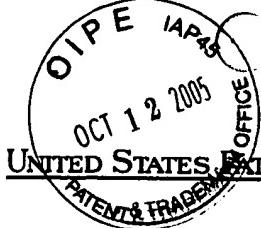

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JAO:JOC/emt

Date: October 12, 2005

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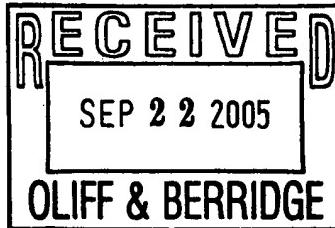


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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY.DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/531,048	04/12/2005	1754	900	123487	1	11	3

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FILING RECEIPT



OC000000017002890

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Power of Attorney: The patent practitioners associated with Customer Number 25944.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP03/13189 10/15/2003

Foreign Applications

JAPAN 2002-303923 10/18/2002

Projected Publication Date: 12/22/2005

Non-Publication Request: No

Early Publication Request: No

Title

Silicon carbide-based catalytic material and process for producing the same

Preliminary Class

502

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